ELSEVIER

Thin Solid Films 254 (1995) 297–298

thin solid films

Author Index of Volume 254

Acharya, B.S. 47
Ageev, V.P. 92
Amanullah, F.M. 28
Antolini, F. 252
Azens, A. 1

Babu, S.V. 92
Banash, M.A. 7
Baran, J. 229
Basak, D. 181
Bickmann, K. 39
Birnie III, D.P. 175
Böffgen, M. 96
Borovikov, A.Yu. 229
Byckov, V.N. 229

Chattopadhyay, K.K. 111
Chaudhuri, S. 111
Chicot, D. 123
Clark, T.J. 7
Corbach, H.D.v. 153
Cruse, R.W. 7

Day, M.E. 285
Decher, G. 246
Delfino, M. 285
Dorignac, D. 75
Dworschak, W. 65

Ehrhardt, H. 65

Fabes, B.D. 175
Fair, J.A. 285
Fayeulle, S. 131
Fech, J. 7
Fransen, T. 153
Fuchs, H. 147

Ge, Q. 10
Gellings, P.J. 153
Glachant, A. 54
Gould, R.D. 187, 291
Granqvist, C.G. 1
Guziewicz, M. 194

Haanappel, V.A.C. 153
Hari Babu, V. 28
Hashimoto, M. 224
Hauck, J. 39
Hwang, B.J. 23
Hwang, U.-H. 16

Iwatsu, F. 103

Jiménez-Garay, R. 83
Jung, K. 65

Käding, O. 139
Kaida, S. 169
Kakuta, A. 218
Kaminska, A.M. 194
Kemnitzer, R. 147
Kim, C.H. 273
Kim, J.S. 33
Kim, T.S. 273
Kim, T.W. 61
Kim, Y. 61
Kitai, A.H. 268
Koizumi, Y. 169
Kokura, M. 103
Kononenko, T.V. 92
Kun, Z.K. 216
Küppers, J. 147

Langlais, F. 75
Lee, K.L. 23
Lesage, J. 123
Lin, Z. 3
Liu, Z. 3
Lopez, M.G. 291
Loumagne, F. 75
Lu, X. 263
Lux-Steiner, M. 147
Lvov, Y.M. 246, 257

Ma, S. 263
Marchewka, M.K. 229
Márquez, E. 83
Maruyama, H. 224
Marzouk, H.A. 33
Mathew, S. 278
Matthias, E. 139
Metselaar, H.S.C. 153
Min, S.-K. 61
Mininni, R.M. 7
Møller, P.J. 10
Morikawa, H. 103
Mukerjee, P.S. 278
Murakami, M. 240

Nakai, H. 224
Nalwa, H.S. 218
Nambu, T. 240
Naslain, R. 75

Naumovets, A.G. 229
Nayak, B.B. 47
Nazarenkov, F.A. 164
Neske, E. 139
Nichogi, K. 240
Nicolini, C. 252
Nowak, M. 200

Oh, M.H. 273
Okimura, H. 169
Ouyang, X. 268

Pal, A.K. 111
Pal, R. 111
Parhi, N. 47
Patrykiejew, A. 116
Petzoldt, S. 139
Podzelinsky, A.V. 229
Pratap, K.J. 28
Puchkovskaya, G.A. 229

Qiu, H. 224

Rakhenko, V.G. 92
Ramalho, A. 131
Ramírez-Malo, J.B. 83
Ramsden, J.J. 246
Ratajczak, H. 229
Reichling, M. 139
Reucroft, P.J. 33
Reuter, H. 96
Rohman, S.J. 7

Safari, A. 211
Schamm, S. 75
Schimmel, T. 147
Schmitt, H. 96
Schoch, Jr., K.F. 216
Sen, S.K. 181
Seth, J. 92
Sévely, J. 75
Shihub, S.I. 187
Siegel, J. 139
Siegele, R. 268
Skurk, H. 139
Smith, J.D.B. 216
Sokołowski, S. 116
Sterligov, V.A. 164
Stjerna, B. 1
Strelnitsky, V.E. 92
Styopkin, V.I. 229
Su, W.-F.A. 216
Swanepoel, R. 83

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Taomoto, A. 240
Terao, T. 103
Trotta, M. 252
Tsai, W. 285

Vendel, D.v.d. 153
Vieira, M.T. 131
Vijayakumar, K.P. 278
Villares, P. 83

Wang, W. 263

Yoon, S.-G. 211
Young, R.M. 216

Zagórski, R. 116
Zaitsev, S.Y. 257
Zelinski, B.J.J. 175
Zhang, Z. 263
Zheng, J. 263
Zong, B.Q. 3

ELSEVIER

Thin Solid Films 254 (1995) 299–302

thin solid films

Subject Index of Volume 254

Adsorption
a two-dimensional Lennard-Jones lattice gas III: Monte Carlo study of ordering on rectangular lattices, 116
determination of optical constants of molecular films assembled via alternate polyion adsorption, 246
Alloys
characterization of isochronally and isothermally annealed indium tin oxide thin films, 28
Aluminium oxide
the mechanical properties of thin alumina films deposited by metal–organic chemical vapour deposition, 153
Amorphous materials
a.c. electrical properties of vacuum deposited Au–SiO_x–Au sandwich structures prior to electroforming, 291
determination of optical constants and average thickness of inhomogeneous-rough thin films using spectral dependence of optical transmittance, 200
mechanism of photo-stimulated processes in GeO_x films, 164
optical characterization of wedge-shaped thin films of amorphous arsenic trisulphide based only on their shrunk transmission spectra, 83
Annealing
characterization of isochronally and isothermally annealed indium tin oxide thin films, 28
Auger electron spectroscopy
constructive versus destructive effects of electron beam irradiation: an application to plasma nitridation of SiO_2 thin films, 54

Biomaterials
X-ray reflectivity analysis of Langmuir–Blodgett films of reaction center proteins from photosynthetic bacteria, 257
Boron nitride
growth mechanism of cubic boron nitride in a r.f. glow discharge, 65

Cadmium sulphide
optical and surface properties of spray-pyrolysed CdS thin films, 278
Capacitors
electrical, dielectric and optical properties of $M/Y_2O_3/M$ devices, 181
Carbon
lithographic application of diamond-like carbon films, 92
Ceramics
a study of Cu growth on an yttria-stabilized ZrO_2(100) surface, 10
$(Ba_{0.5}, Sr_{0.5})TiO_3$ thin film preparation by r.f. magnetron sputtering and its electric properties, 211
porosity and composition effects in sol–gel derived interference filters, 175
the use of infrared interference spectra to measure ceramic coating thickness in a CVD reactor, 7

Chalcogens
optical characterization of wedge-shaped thin films of amorphous arsenic trisulphide based only on their shrunk transmission spectra, 83
Chemical vapour deposition
deposition and structural characterization of ZrO_2 and yttria-stabilized ZrO_2 films by chemical vapor deposition, 33
diamond growth on porous silicon by hot-filament chemical vapor deposition, 3
physicochemical properties of SiC-based ceramics deposited by low pressure chemical vapor deposition from CH_3SiCl_3–H_2, 75
the mechanical properties of thin alumina films deposited by metal–organic chemical vapour deposition, 153
the use of infrared interference spectra to measure ceramic coating thickness in a CVD reactor, 7
Coatings
absolute hardness of films and coatings, 123
in-situ investigation of laser ablation of thin films, 139
porosity and composition effects in sol–gel derived interference filters, 175
the mechanical properties of thin alumina films deposited by metal–organic chemical vapour deposition, 153
the role of interfacial films in the friction and wear properties of W-Co-C sputtered coatings, 131
the use of infrared interference spectra to measure ceramic coating thickness in a CVD reactor, 7
Conductivity
a.c. electrical properties of vacuum deposited Au–SiO_x–Au sandwich structures prior to electroforming, 291
conductivity and stability of polypyrrole film electrosynthesized on a PbO_2/SnO_2/Ti substrate, 23
frequency dependence of electronic conduction parameters in evaporated thin films of cobalt phthalocyanine, 187
properties of sputtered amorphous and microcrystalline GaAs films, 96
Copper
a field ion microscope study on vapor deposition of copper on tungsten, 103
a study of Cu growth on an yttria-stabilized ZrO_2(100) surface, 10
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1

Deposition process
characterization of isochronally and isothermally annealed indium tin oxide thin films, 28
conductivity and stability of polypyrrole film electrosynthesized on a PbO_2/SnO_2/Ti substrate, 23
the thickness dependence of $(Ba_{0.5}Sr_{0.5})TiO_3$ thin films deposited on indium tin oxide-coated glass substrate using r.f. magnetron sputtering, 273

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Depth profiling
characterization of isochronally and isothermally annealed indium tin oxide thin films, 28
constructive versus destructive effects of electron beam irradiation: an application to plasma nitridation of SiO_2 thin films, 54
Diamond
diamond growth on porous silicon by hot-filament chemical vapor deposition, 3
Dielectric properties
electrical, dielectric and optical properties of $M/Y_2O_3/M$ devices, 181
frequency dependence of electronic conduction parameters in evaporated thin films of cobalt phthalocyanine, 187
the thickness dependence of $(Ba_{0.5}Sr_{0.5})TiO_3$ thin films deposited on indium tin oxide-coated glass substrate using r.f. magnetron sputtering, 273
Dielectrics
$(Ba_{0.5}, Sr_{0.5})TiO_3$ thin film preparation by r.f. magnetron sputtering and its electric properties, 211
in-situ investigation of laser ablation of thin films, 139

Elastic properties
strain in thick epitaxial layers, 39
Electrical properties and measurements
a.c. electrical properties of vacuum deposited $Au-SiO_x-Au$ sandwich structures prior to electroforming, 291
electrical properties of p-type InSb thin films prepared by coevaporation with excess antimony, 169
frequency dependence of electronic conduction parameters in evaporated thin films of cobalt phthalocyanine, 187
Electromigration
constructive versus destructive effects of electron beam irradiation: an application to plasma nitridation of SiO_2 thin films, 54
Electron energy loss spectroscopy
physicochemical properties of SiC-based ceramics deposited by low pressure chemical vapor deposition from $CH_3SiCl_3-H_2$, 75
Electron scattering
correlation of electrical resistivity and grain size in sputtered titanium films, 285
Electron stimulated desorption
constructive versus destructive effects of electron beam irradiation: an application to plasma nitridation of SiO_2 thin films, 54
Electronic devices
electroluminescent edge emission from poly(phenylene vinylene) films, 216
Ellipsometry
a new ellipsometric model of wet and dry etched GaAs surfaces, 194
mechanism of photo-stimulated processes in GeO_x films, 164
optical and surface properties of spray-pyrolysed CdS thin films, 278
porosity and composition effects in sol–gel derived interference filters, 175
Epitaxy
strain in thick epitaxial layers, 39
Etching
a new ellipsometric model of wet and dry etched GaAs surfaces, 194
effect of etching on the surface morphology and grain boundary parameters of Cu-rich $CuInSe_2$ films, 111
mechanism of photo-stimulated processes in GeO_x films, 164
Evaporation
electrical properties of p-type InSb thin films prepared by coevaporation with excess antimony, 169
mechanism of photo-stimulated processes in GeO_x films, 164

Field ion microscopy
a field ion microscope study on vapor deposition of copper on tungsten, 103
Fluorine
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1
Fourier transform infrared spectroscopy
investigation of stearic acid and manganese stearate films obtained by Langmuir–Blodgett and vacuum deposition methods, 229
the use of infrared interference spectra to measure ceramic coating thickness in a CVD reactor, 7

Gallium arsenide
magnetotransport and electric subband studies of Si-delta-doped $Al_{0.27}Ga_{0.73}As/GaAs$ single quantum wells grown by metalorganic chemical vapour deposition, 61
properties of sputtered amorphous and microcrystalline GaAs films, 96
Glow discharge
growth mechanism of cubic boron nitride in a r.f. glow discharge, 65
Grain boundary
effect of etching on the surface morphology and grain boundary parameters of Cu-rich $CuInSe_2$ films, 111
Growth mechanism
a field ion microscope study on vapor deposition of copper on tungsten, 103
a study of Cu growth on an yttria-stabilized $ZrO_2(100)$ surface, 10
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1
growth mechanism of cubic boron nitride in a r.f. glow discharge, 65

Hall effect
electrical properties of p-type InSb thin films prepared by coevaporation with excess antimony, 169
Hardness
absolute hardness of films and coatings, 123
Heat treatment
effect of temperature on optical properties of reaction centres organized in Langmuir–Blodgett films, 252

Indium antimonide
electrical properties of p-type InSb thin films prepared by coevaporation with excess antimony, 169
Infrared spectroscopy
growth mechanism of cubic boron nitride in a r.f. glow discharge, 65
Interfaces
absolute hardness of films and coatings, 123
Ion plating
effects of substrate temperature on TiN films deposited by ion plating using spatial magnetic field, 16

Langmuir–Blodgett films
effect of temperature on optical properties of reaction centres organized in Langmuir–Blodgett films, 252
investigation of stearic acid and manganese stearate films obtained by Langmuir–Blodgett and vacuum deposition methods, 229

mixed-stack charge-transfer films prepared by Langmuir–Blodgett technique and donor doping, 240
structural and optical non-linear characters of hemicyanine derivatives in Langmuir–Blodgett monolayers, 263
X-ray reflectivity analysis of Langmuir–Blodgett films of reaction center proteins from photosynthetic bacteria, 257
Laser ablation
in-situ investigation of laser ablation of thin films, 139
Laser irradiation
lithographic application of diamond-like carbon films, 92
Luminescence
electroluminescent edge emission from poly(phenylene vinylene) films, 216
rare-earth-doped transparent yttrium silicate thin film phosphors for colour displays, 268

Magnetic properties and measurements
ferromagnetic resonance in Ni films produced by biased d.c. sputter deposition onto SiO_2 and Si(100), 224
Metals
in-situ investigation of laser ablation of thin films, 139
Monolayers
absolute hardness of films and coatings, 123
structural and optical non-linear characters of hemicyanine derivatives in Langmuir–Blodgett monolayers, 263
Multilayers
determination of optical constants of molecular films assembled via alternate polyion adsorption, 246

Nanostructures
magnetotransport and electric subband studies of Si-delta-doped $Al_{0.27}Ga_{0.73}As$/GaAs single quantum wells grown by metalorganic chemical vapour deposition, 61
physicochemical properties of SiC-based ceramics deposited by low pressure chemical vapor deposition from CH_3SiCl_3–H_2, 75
writing and deleting atomic scale structures with the scanning tunneling microscope, 147
Nickel
ferromagnetic resonance in Ni films produced by biased d.c. sputter deposition onto SiO_2 and Si(100), 224

Optical coatings
porosity and composition effects in sol–gel derived interference filters, 175
Optical properties
a new ellipsometric model of wet and dry etched GaAs surfaces, 194
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1
determination of optical constants and average thickness of inhomogeneous-rough thin films using spectral dependence of optical transmittance, 200
determination of optical constants of molecular films assembled via alternate polyion adsorption, 246
electrical, dielectric and optical properties of M/Y_2O_3/M devices, 181
effect of temperature on optical properties of reaction centres organized in Langmuir–Blodgett films, 252
optical and surface properties of spray-pyrolysed CdS thin films, 278
optical characterization of wedge-shaped thin films of amorphous arsenic trisulphide based only on their shrunk transmission spectra, 83
rare-earth-doped transparent yttrium silicate thin film phosphors for colour displays, 268
structural and optical non-linear characters of hemicyanine derivatives in Langmuir–Blodgett monolayers, 263
third-order non-linear optical properties of donor- and acceptor-substituted metallophthalocyanines, 218
Organic substances
frequency dependence of electronic conduction parameters in evaporated thin films of cobalt phthalocyanine, 187
mixed-stack charge-transfer films prepared by Langmuir–Blodgett technique and donor doping, 240
Organometallic vapour deposition
magnetotransport and electric subband studies of Si-delta-doped $Al_{0.27}Ga_{0.73}As$/GaAs single quantum wells grown by metalorganic chemical vapour deposition, 61
the mechanical properties of thin alumina films deposited by metal–organic chemical vapour deposition, 153
Oxides
deposition and structural characterization of ZrO_2 and yttria-stabilized ZrO_2 films by chemical vapor deposition, 33
rare-earth-doped transparent yttrium silicate thin film phosphors for colour displays, 268

Phase transitions
a two-dimensional Lennard-Jones lattice gas III: Monte Carlo study of ordering on rectangular lattices, 116
mixed-stack charge-transfer films prepared by Langmuir–Blodgett technique and donor doping, 240
Photovoltage
properties of sputtered amorphous and microcrystalline GaAs films, 96
Physical vapour deposition
$(Ba_{0.5}, Sr_{0.5})TiO_3$ thin film preparation by r.f. magnetron sputtering and its electric properties, 211
effects of substrate temperature on TiN films deposited by ion plating using spatial magnetic field, 16
the role of interfacial films in the friction and wear properties of W-Co-C sputtered coatings, 131
the thickness dependence of $(Ba_{0.5}Sr_{0.5})TiO_3$ thin films deposited on indium tin oxide-coated glass substrate using r.f. magnetron sputtering, 273
Plasma processing and deposition
effects of substrate temperature on TiN films deposited by ion plating using spatial magnetic field, 16
ferromagnetic resonance in Ni films produced by biased d.c. sputter onto SiO_2 and Si(100), 224
Polymers
conductivity and stability of polypyrrole film electrosynthesized on a PbO_2/SnO_2/Ti substrate, 23
determination of optical constants of molecular films assembled via alternate polyion adsorption, 246
electroluminescent edge emission from poly(phenylene vinylene) films, 216

Resistivity
correlation of electrical resistivity and grain size in sputtered titanium films, 285
preparation and characterization of Bi_2S_3–PbS thin films by X-ray diffraction, scanning electron microscopy and resistivity studies, 47

Scanning electron microscopy
preparation and characterization of Bi_2S_3–PbS thin films by X-ray diffraction, scanning electron microscopy and resistivity studies, 47
Scanning tunnelling microscopy
writing and deleting atomic scale structures with the scanning tunneling microscope, 147

Schottky barrier
electrical, dielectric and optical properties of $M/Y_2O_3/M$ devices, 181
Second harmonic generation
structural and optical non-linear characters of hemicyanine derivatives in Langmuir–Blodgett monolayers, 263
Selenides
writing and deleting atomic scale structures with the scanning tunneling microscope, 147
Semiconductors
determination of optical constants and average thickness of inhomogeneous-rough thin films using spectral dependence of optical transmittance, 200
magnetotransport and electric subband studies of Si-delta-doped $Al_{0.27}Ga_{0.73}As/GaAs$ single quantum wells grown by metalorganic chemical vapour deposition, 61
mixed-stack charge-transfer films prepared by Langmuir–Blodgett technique and donor doping, 240
optical characterization of wedge-shaped thin films of amorphous arsenic trisulphide based only on their shrunk transmission spectra, 83
Silicon
determination of optical constants and average thickness of inhomogeneous-rough thin films using spectral dependence of optical transmittance, 200
diamond growth on porous silicon by hot-filament chemical vapor deposition, 3
Silicon carbide
physicochemical properties of SiC-based ceramics deposited by low pressure chemical vapor deposition from $CH_3SiCl_3–H_2$, 75
Silicon oxide
a.c. electrical properties of vacuum deposited $Au–SiO_x–Au$ sandwich structures prior to electroforming, 291
Sputtering
$(Ba_{0.5}, Sr_{0.5})TiO_3$ thin film preparation by r.f. magnetron sputtering and its electric properties, 211
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1
correlation of electrical resistivity and grain size in sputtered titanium films, 285
properties of sputtered amorphous and microcrystalline GaAs films, 96
rare-earth-doped transparent yttrium silicate thin film phosphors for colour displays, 268
the thickness dependence of $(Ba_{0.5}Sr_{0.5})TiO_3$ thin films deposited on indium tin oxide-coated glass substrate using r.f. magnetron sputtering, 273
Stability
conductivity and stability of polypyrrole film electrosynthesized on a $PbO_2/SnO_2/Ti$ substrate, 23
Stress
ferromagnetic resonance in Ni films produced by biased d.c. sputter deposition onto SiO_2 and Si(100), 224
strain in thick epitaxial layers, 39
Sulphides
preparation and characterization of $Bi_2S_3–PbS$ thin films by X-ray diffraction, scanning electron microscopy and resistivity studies, 47
Surface and interface states
effect of etching on the surface morphology and grain boundary parameters of Cu-rich $CuInSe_2$ films, 111
Surface roughness
a new ellipsometric model of wet and dry etched GaAs surfaces, 194
effect of etching on the surface morphology and grain boundary parameters of Cu-rich $CuInSe_2$ films, 111
optical and surface properties of spray-pyrolysed CdS thin films, 278
Surface structure
a study of Cu growth on an yttria-stabilized $ZrO_2(100)$ surface, 10

Titanium
correlation of electrical resistivity and grain size in sputtered titanium films, 285
Titanium nitride
effects of substrate temperature on TiN films deposited by ion plating using spatial magnetic field, 16
Transmission electron microscopy
investigation of stearic acid and manganese stearate films obtained by Langmuir–Blodgett and vacuum deposition methods, 229
Tribology
the role of interfacial films in the friction and wear properties of W-Co-C sputtered coatings, 131
Tungsten
a field ion microscope study on vapor deposition of copper on tungsten, 103
the role of interfacial films in the friction and wear properties of W-Co-C sputtered coatings, 131
Tungsten oxide
chemically enhanced sputtering in fluorine-containing plasmas: application to tungsten oxyfluoride, 1

Vacuum deposition
investigation of stearic acid and manganese stearate films obtained by Langmuir–Blodgett and vacuum deposition methods, 229

X-ray diffraction
deposition and structural characterization of ZrO_2 and yttria-stabilized ZrO_2 films by chemical vapor deposition, 33
preparation and characterization of $Bi_2S_3–PbS$ thin films by X-ray diffraction, scanning electron microscopy and resistivity studies, 47
strain in thick epitaxial layers, 39
X-ray photoelectron spectroscopy
deposition and structural characterization of ZrO_2 and yttria-stabilized ZrO_2 films by chemical vapor deposition, 33
X-ray scattering
X-ray reflectivity analysis of Langmuir–Blodgett films of reaction center proteins from photosynthetic bacteria, 257